Valley relaxation of resident electrons and holes in a monolayer semiconductor: Dependence on carrier density and the role of substrate-induced disorder

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Using time-resolved optical Kerr rotation, we measure the low-temperature valley dynamics of resident electrons and holes in exfoliated WSe₂ monolayers as a systematic function of carrier density. In an effort to reconcile the many disparate timescales of carrier valley dynamics in monolayer semiconductors reported to date, we directly compare the doping-dependent valley relaxation in two electrostatically gated WSe₂ monolayers having different dielectric environments. In a fully encapsulated structure (hBN/WSe₂/hBN, where hBN is hexagonal boron nitride), valley relaxation is found to be monoexponential. The valley relaxation time τ_v is quite long (∼10 μs) at low carrier densities, but decreases rapidly to less than 100 ns at high electron or hole densities $\ge 2 \times 10^{12}$ cm⁻². In contrast, in a partially encapsulated WSe₂ monolayer placed directly on silicon dioxide (hBN/WSe $_2$ /SiO₂), carrier valley relaxation is multiexponential at low carrier densities. The difference is attributed to environmental disorder from the SiO₂ substrate. Unexpectedly, very small out-of-plane magnetic fields can increase τ_v , especially in the hBN/WSe₂/SiO₂ structure, suggesting that localized states induced by disorder can play an important role in depolarizing spins and mediating the valley relaxation of resident carriers in monolayer transition-metal dichalcogenide semiconductors.

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I. INTRODUCTION AND BACKGROUND

Much of the current excitement surrounding the family of monolayer transition-metal dichalcogenide (TMD) semiconductors such as $MoS₂$ and $WSe₂$ derives from notions of utilizing "valley pseudospin" degrees of freedom as a basis for storing and processing quantum information $[1-3]$. Although many of these ideas originated from long-standing considerations of valley degrees of freedom in other materials such as silicon, AlAs, and graphene $[4–7]$, monolayer TMD semiconductors have revitalized interests in "valleytronics" due to the ease with which specific valleys in momentum space (namely, the K and K' points in the Brillouin zone) can be selectively populated and probed simply by using and detecting right- or left-circularly polarized (RCP or LCP) light. This convenient set of valley-specific optical selection rules in the monolayer TMDs, which do not exist in most conventional semiconductors or in graphene, arises from their lack of inversion symmetry, and large spin-orbit coupling [\[8,9\]](#page-8-0).

Analogous to the keen interest in electron, hole, and exciton spin relaxation during the early days of semiconductor spintronics [\[10–12\]](#page-8-0), measurements of valley relaxation in monolayer TMDs are currently a focus of attention for potential applications in valleytronics. Considerable initial attention followed from early photoluminescence (PL) studies in 2012 demonstrating that when certain monolayer TMDs were photoexcited by circularly polarized light, the resulting PL was strongly cocircularly polarized [\[13–16\]](#page-8-0), suggesting that valley degrees of freedom might be especially robust and long lived. However, because PL necessarily originates from the optical recombination of transient excitons, copolarized PL is equally consistent with very short exciton lifetimes (i.e., even shorter than the timescale of fast exciton valley scattering). And indeed, very fast exciton and trion PL lifetimes in the 1–100 ps range were subsequently revealed in time-resolved PL studies [\[17–19\]](#page-8-0).

While the dynamics of excitons and exciton valley scattering in monolayer TMDs [\[19–28\]](#page-8-0) are surely very important for certain optoelectronic applications, a different and arguably more relevant question for many putative valleytronic applications is as follows: "What are the intrinsic valley relaxation timescales of the *resident* electrons and holes that exist in *n*-type doped and *p*-type doped TMD monolayers?" In this case, electron-hole exchange interactions, which can be a very efficient valley scattering and decoherence mechanism for polarized excitons [\[19–28\]](#page-8-0), are absent. Therefore, much longer valley relaxation timescales may be expected for resident electrons and holes because the spin-orbit splitting and resulting spin-valley locking in the conduction bands and in (especially) the valence bands mandates that valley scattering at low temperatures requires not only a large momentum change $(K \leftrightarrow K')$, but *also* a spin flip [\[9\]](#page-8-0).

Similar to the way in which long spin lifetimes of resident electrons and holes enabled spin-based device demonstrations in conventional semiconductors and graphene [\[29–](#page-8-0)[32\]](#page-9-0), it is

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therefore the valley relaxation of the resident electrons and holes in doped TMD monolayers and heterostructures that will likely determine the functionality of many valley-based device concepts. To this end, systematic studies of resident carrier valley dynamics in doped TMD monolayers are essential, particularly as a function of carrier density, temperature, and overall material quality.

Experimental studies along these lines commenced in about 2015, typically using polarization-resolved optical pump-probe methods such as time-resolved circular dichroism and Kerr or Faraday rotation, techniques that had been developed and refined in the preceding decades to explore spin lifetimes and spin coherence in conventional III-V and II-VI semiconductors [\[33,34\]](#page-9-0). Initial measurements focused on MoS_2 , WS_2 , and WSe_2 monolayers grown by chemical vapor deposition (CVD), which were unintentionally doped with either electrons or holes [\[35–38\]](#page-9-0). These studies typically revealed multiexponential valley relaxation with longer timescales on the order of several nanoseconds at low temperatures (i.e., roughly $10-100\times$ longer than the measured recombination times of the "bright" excitons and trions [\[17,18\]](#page-8-0), and also the nominally forbidden "dark" excitons and trions [\[39–43\]](#page-9-0)). While very encouraging, the CVD-grown monolayers studied in [\[35–38\]](#page-9-0) were not charge adjustable, and moreover they exhibited broad optical absorption lines (many tens of meV) indicating significant inhomogeneous broadening, likely due to the fact that they were grown by CVD, directly on $SiO₂$ or sapphire substrates, with surfaces that were not encapsulated or passivated.

Subsequent studies then focused on carrier valley relaxation in mechanically exfoliated (but still unpassivated) $WSe₂$ monolayers that exhibited improved optical quality, and which afforded some degree of charge tunability via electrostatic gating [\[44\]](#page-9-0). Here, ∼100 ns valley relaxation of resident electrons was found in the heavily *n*-type doped regime, while a very long microsecond-duration valley relaxation of holes was observed when the same monolayer was gated *p*-type (although a systematic dependence on carrier density was not performed). Similarly, pump-probe measurements of WSe₂/MoS₂ *bi*layers, in which photoexcited holes quickly migrated to the WSe₂ layer and then relaxed independently from the electrons, also showed long microsecond valley relaxation of holes [\[45\]](#page-9-0).

In parallel, at about this time (2017) it became widely appreciated that the optical quality of TMD monolayers could be significantly improved via full encapsulation between slabs of exfoliated hexagonal boron nitride (hBN) [\[46–48\]](#page-9-0). This key advance made it possible to achieve TMD monolayers with not only exceptionally narrow (a few meV) exciton linewidths approaching the homogeneous limit, but also with the ability to be continuously gated all the way from the heavily electrondoped regime to the heavily hole-doped regime [\[48,49\]](#page-9-0), likely owing to a reduction of defects, traps, and localized states in the WSe₂ forbidden band gap. Using hBN-encapsulated structures, *mono*exponential valley relaxation of resident electrons and holes was observed, with timescales of order 100 ns (for electrons) to several microseconds (for holes) [\[50,51\]](#page-9-0). Crucially, these long timescales were validated by passive optical detection of the thermodynamic valley fluctuations ('valley noise') of the resident carriers in thermal equilibrium (i.e., no pump laser or excitation was used) [\[51\]](#page-9-0), confirming that the long decays originate from the intrinsic valley relaxation of the resident electrons and holes themselves, and not from, e.g., any type of long-lived dark or trapped exciton [\[52\]](#page-9-0).

As outlined above, a wide range of electron and hole valley relaxation timescales have been reported to date, which is due in part to the significant improvement in the quality and passivation of TMD monolayers over the past several years, and also because different studies reported on samples with different specific carrier densities. Here, we attempt to provide a more unified understanding of resident carrier valley relaxation in monolayer TMD semiconductors, by directly comparing the detailed doping dependence of valley relaxation in two electrostatically gated WSe₂ monolayers having different surrounding dielectric environments. In a *fully encapsulated* WSe₂ monolayer (hBN/WSe₂/hBN), valley relaxation is found to be almost perfectly monoexponential. The valley relaxation time τ_v is quite long (\sim 10 μ s) at low carrier densities, but decreases rapidly to less than 100 ns at high electron or high hole densities exceeding $∼2 × 10¹²$ cm⁻². In contrast, in a *partially encapsulated* WSe₂ monolayer placed directly on a silicon dioxide substrate $(hBN/WSe₂/SiO₂$, another common assembly motif), carrier valley relaxation is found to be multiexponential at low densities, exhibiting a faster initial decay followed by a slow $(∼10 \mu s)$ relaxation. The difference is attributed to in-gap states in the $WSe₂$ introduced by dielectric disorder in the $SiO₂$ substrate, which has an especially strong influence on monolayer TMDs in the low carrier density regime. Similar to the fully encapsulated case, however, this slow relaxation accelerates by over two orders of magnitude with increasing electron or hole doping. Increasing temperatures also accelerate valley relaxation, and, crucially, the unexpected influence of small perpendicular magnetic fields is measured and discussed in the context of localized in-gap states that can depolarize spins and thereby mediate carrier valley relaxation.

II. EXPERIMENTAL RESULTS

Figure [1](#page-2-0) shows the two different electrostatically gated WSe₂ monolayer structures measured in this work. To ensure accurate comparisons, both structures incorporate a single WSe₂ monolayer that was mechanically exfoliated from the same high-quality bulk crystal grown by the self-flux method, in which the density of lattice defects is much lower than in bulk crystals grown by chemical vapor transport [\[53\]](#page-9-0). Both structures were assembled using the same van der Waals dry stacking method to provide clean interfaces between the $WSe₂$ and its adjacent dielectric materials.

"Sample A" [Fig. $1(a)$] is representative of modern structures exhibiting very high optical quality: it is a *fully* hBN-encapsulated WSe₂ monolayer (hBN/WSe₂/hBN), with top and bottom gates and a contact electrode made from flakes of few-layer graphite (FLG). Here, the complete encapsulation by pristine (not postprocessed) exfoliated hBN flakes provides an atomically smooth and largely defect-free dielectric environment $[54]$ entirely surrounding the WSe₂ monolayer, which leads to very narrow features in optical spectra, as discussed below. Full hBN encapsulation is now widely recognized to yield monolayer TMD structures with

FIG. 1. (a) Optical micrograph and cross-sectional schematic of "sample A," which is a *fully* encapsulated WSe₂ monolayer (hBN/WSe2/hBN). All hBN layers are ∼30 nm thick. The resident carrier density is electrostatically tuned via few-layer graphite (FLG) flakes, which serve as the top and bottom gates and contact electrode. The top and bottom gates are held at the same potential and swept together. (b) An optical micrograph and cross-sectional schematic of "sample B," which is a *partially* encapsulated WSe₂ monolayer placed directly on a 300-nm-thick silicon dioxide layer (hBN/WSe₂/SiO₂). Here, the bottom Si⁺⁺ gate is held fixed at −15 V, and the carrier density is varied by the top FLG gate. (c), (d) Intensity maps of the carrier-density-dependent reflectance spectra $\Delta R/R_0$ in samples A and B, respectively. Electron- and hole-doped regimes are clearly visible in both structures, separated by a nominally charge-neutral regime in which the neutral exciton X^0 resonance is visible. Negatively charged and positively charged exciton features (i.e., X^- and X^+ trions) appeared in the electron-doped (*n*-type) and hole-doped (*p*-type) regimes, respectively. Sample A exhibits considerably higher optical quality than sample B, as evidenced by its much narrower X^0 resonance (6 meV vs 35 meV width) and trion resonances, and by the smaller gating range over which the charge-neutral regime appears. Carrier densities were calibrated by the known thicknesses and dielectric constants of the hBN and $SiO₂$ layers, and also (in sample A) by the "kink" in the *X* − resonance at high electron density [\[48\]](#page-9-0). All measurements were performed at 5.8 K.

excellent optical properties and a minimum of inhomogeneous broadening and disorder [\[46,47,55–57\]](#page-9-0).

In contrast, "sample B" [Fig. $1(b)$] is representative of a different, but nonetheless very common, type of van der Waals structure: it is a *partially* encapsulated WSe₂ monolayer that is placed directly on silicon dioxide (hBN/WSe $_2$ /SiO₂). Here, gating is achieved via a top FLG gate electrode and the underlying heavily doped Si substrate. In this case, the $WSe₂$ monolayer is in direct contact with the $SiO₂$, and is therefore in intimate proximity to surface defects, dangling bonds, dielectric disorder, and surface roughness, with a consequent reduction in the optical quality of the TMD monolayer.

The difference in optical and material properties between the two structures is readily apparent in the gate-dependent maps of optical reflectivity, shown in Figs. $1(c)$ and $1(d)$. These maps show normalized reflection spectra $(\Delta R/R_0)$ acquired at low temperature (5.8 K), as the resident carrier density in the $WSe₂$ monolayers is tuned from heavily electron doped (*n*-type), to nominally undoped (charge neutral), to heavily hole doped (*p*-type). For clarity, throughout this paper we use "*n*" and "*p*" when referring to electron and hole densities, respectively. High electron densities (*n*) and high hole densities (*p*) exceeding 5×10^{12} cm⁻² are achieved in both structures, thanks to the dual-gating configuration. Importantly, no hysteresis as a function of gate voltage or slow drifts were observed in the measured optical properties of the $WSe₂$ [\[58\]](#page-9-0), likely due to the use of pristine (never postprocessed) hBN encapsulation layers, and because (in sample B) the bottom Si^{++} gate voltage is never varied.

In the fully encapsulated sample A [Fig. $1(c)$], a series of sharp exciton resonances are observed as a function of carrier density. The neutral exciton resonance (X^0) at ∼1.733 eV appears only in a narrow gating region around the charge neutrality point. When *n* and *p* exceed ∼0.3 × 10¹² cm⁻², strong negatively charged exciton (*X* [−]) and positively charged exciton (X^+) resonances appear, respectively, at ~1.700 and 1.710 eV. The appearance of charged excitons (also called "trions" or "attractive polarons" in the literature) in optical reflectivity spectra indicates a substantive change in the available joint density of states of the WSe₂ monolayer, and

FIG. 2. (a) Schematic of the time-resolved Kerr rotation (TRKR) experiment. A nonequilibrium spin-valley polarization of the resident carriers in the WSe₂ monolayer is induced by circularly polarized (RCP or LCP) pump pulses from a 645 nm (1.922 eV) diode laser. The induced polarization is detected by the Kerr rotation θ_K imparted on time-delayed and linearly polarized probe pulses from a wavelengthtunable Ti:sapphire laser that was typically tuned to the peak of the induced Kerr response (cf. Fig. [3\)](#page-5-0). A pulse-picker (PP) reduced the repetition rate of the Ti:sapphire laser to allow accurate measurement of long valley decays, and the pump laser is synchronized to the PP [\[44\]](#page-9-0). LP: linear polarizer, WBS: Wollaston beam splitter. (b) TRKR signals from sample A (fully encapsulated), at different electron (*n*) and hole (*p*) carrier densities. The decays are monoexponential, except for a very slight deviation at short timescales at the lowest densities. The signals reveal the relaxation of optically induced valley polarization of resident carriers, which in monolayer TMDs is intimately linked to carrier spin polarization due to spin-valley locking [\[9\]](#page-8-0). (c) The corresponding valley relaxation time τ*^v* versus carrier density; τ*^v* is sharply peaked at low carrier density. (d) TRKR from sample B (partially encapsulated). Here, at low carrier densities the valley relaxation exhibits a faster initial decay that is followed by a slower exponential decay. (e) The lifetime τ_v of the slow valley relaxation is also peaked at low carrier density, similar to sample A. All measurements were performed at 5.8 K. The diagrams depict localized in-gap states (with nearly degenerate spin levels) that can potentially mediate the valley depolarization of resident carriers, especially at small carrier densities.

therefore the absorption oscillator strength, that is due to the occupation of the conduction bands (CB) and valence bands (VB) by resident carriers. At large electron doping ($n > 2 \times$ 10^{12} cm⁻²), an additional resonance appears at lower energy, which further redshifts with increasing *n*. Although the nature of this resonance is not yet fully understood [\[48,59\]](#page-9-0), in keeping with recent studies we label this peak as X^{-1} . Importantly, these reflectivity spectra are in excellent agreement with other recent measurements of gate-dependent absorption and reflection of hBN-encapsulated WSe₂ monolayers $[48,49]$.

In the partially encapsulated sample B [Fig. $1(d)$], we observe a qualitatively similar dependence of $\Delta R/R_0$ on carrier density. However, the exciton resonances are spectrally much broader and weaker. The neutral exciton X^0 is clearly visible near the charge neutrality point, but is spectrally broad (\sim 35 meV versus \sim 6 meV in the sample A). *X*[±] charged exciton features are also broader, and do not appear until the carrier density exceeds \sim 1 × 10¹² cm⁻², suggesting the presence of ample states in the nominally forbidden band gap of the WSe₂ monolayer, likely introduced by the close proximity to the $SiO₂$ substrate. Note that the reflection maxima and minima are inverted (in comparison to sample A), due to the different layer structure and therefore different optical interference in reflection.

Figure $2(a)$ depicts the time-resolved Kerr rotation (TRKR) experiment that was used to measure the valley dynamics of the resident carriers. The gated WSe₂ structures were mounted on the cold finger of a small optical cryostat. A pulsed diode laser generated short (80 ps) optical pump pulses at 645 nm (1.922 eV), which were then circularly polarized and focused to a $10 \mu m$ diameter spot on the sample. Owing to the valley-specific optical selection rules in monolayer WSe₂, the above-gap pump photoexcites valley- and spin-polarized electrons and holes into the monolayer, which rapidly relax to the band edges and form bright and dark excitons and trions, which subsequently scatter and recombine on short $(\leq 1 \text{ ns})$ timescales [\[17–19,](#page-8-0)[39–43\]](#page-9-0). Invariably, some of the possible recombination pathways involved phonon-assisted transitions, nonradiative recombination, and the existing resident carriers, the net effect of which induces a nonequilibrium spin and valley polarization to the Fermi sea of resident carriers.

The subsequent relaxation of this pump-induced valley polarization on timescales longer than a few hundred picoseconds was detected via the optical Kerr rotation $\theta_K(t)$ imparted on time-delayed and linearly polarized probe pulses (150 fs) from a wavelength-tunable Ti:sapphire laser focused to a small 3μ m diameter spot on the sample. To enable the accurate and unambiguous measurement of the long $(0.1-10 \mu s)$ valley relaxation observed in this work, it was necessary to reduce the repetition rate of the Ti:sapphire laser by an acousto-optic pulse picker, so that the time interval between excitation cycles was longer than the measured relaxation time. The time delay between the pump and probe pulses was synchronized and controlled by an electronic timing delay [\[44\]](#page-9-0). The pump pulses were modulated between rightand left-circular polarization by a photoelastic modulator, and the pump-induced Kerr rotation was detected by balanced photodiodes and measured via standard lock-in techniques. The probe laser was typically tuned in photon energy to the peak of the induced Kerr response, which coincided with the spectral position of the X^{\pm} charged exciton resonances, as discussed in more detail below.

The carrier-density-dependent valley relaxation in both samples is shown in Figs. $2(b)-2(e)$. Red-shaded and blueshaded traces show measured decays of $\theta_K(t)$ in the electron-doped (*n*-type) and hole-doped (*p*-type) regimes, respectively. In the fully encapsulated sample A, θ_K was observed to decay almost perfectly monoexponentially at all carrier densities [Fig. $2(b)$], suggesting that a single relaxation mechanism dominates. We note that monoexponential decays were also observed in recent time-resolved studies of carrier valley dynamics in high-quality (fully hBN encap-sulated) structures [\[50,51\]](#page-9-0). The valley lifetime τ_v that we observe in sample A is very long at low carrier density (several microseconds), in agreement with recent time-resolved measurements [\[44,45,50,51\]](#page-9-0). However, we find that τ_v drops precipitously with increasing electron or hole doping, to values on the order of 100 ns at high electron or high hole densities $\ge 2 \times 10^{12}$ cm⁻². We emphasize that even this comparatively rapid decay (100 ns) is still approximately two to three orders of magnitude longer than the measured recombination timescales of dark excitons and trions (0.1–1 ns) in monolayer WSe_2 [\[39–43\]](#page-9-0), strongly supporting its interpretation as the slow valley relaxation of resident carriers. The complete set of measured valley lifetimes in sample A as a function of resident carrier density are summarized in Fig. $2(c)$. As just described, τ_v exhibits a sharp maximum at low carrier density.

In contrast, valley dynamics in the partially encapsulated sample B [Fig. $2(c)$] are found to be multiexponential, especially at lower carrier densities below $\leq 2 \times 10^{12}$ cm⁻², suggesting multiple relaxation mechanisms at play. In this low-density regime, a faster initial relaxation is typically followed by a slower and nearly monoexponential decay. These multiexponential decays are similar to time-resolved measurements reported in early studies of CVD-grown and/or unencapsulated TMD monolayers having broader exciton linewidths and reduced optical quality [\[35–38\]](#page-9-0). We associate the slower decay at long time delays with the intrinsic valley relaxation time τ_v , and again find long valley depolarization on the order of 10 μ s at low carrier densities (i.e., similar to sample A). However, τ_v accelerates by over two orders of magnitude with increasing *n*- and *p*-type doping, again similar to sample A (moreover, we note that valley relaxation becomes more closely monoexponential). The dependence of τ_v on carrier density in sample B [Fig. [2\(e\)\]](#page-3-0) roughly follows that observed in sample A [Fig. $2(c)$], although its decrease with *n* and *p* is less abrupt.

We emphasize that samples A and B were fabricated using identical $WSe₂$, hBN, and graphite source materials, the same mechanical exfoliation protocol, and the same van der Waals dry-stacking setup and process. Therefore, we associate the qualitatively different carrier valley dynamics observed in sample B (that is, multiexponential decay) to an extrinsic origin, likely due to dielectric disorder and inhomogeneity introduced by the underlying $SiO₂$. Because $SiO₂$ is a convenient and common substrate for a variety of two-dimensional (2D) material platforms, these disorder potentials and related deleterious effects have been studied carefully over the past years, particularly in relation to the properties of $SiO₂$ -supported graphene [\[54,](#page-9-0)[60,61\]](#page-10-0), and more recently in relation to the optical and electronic properties of TMD monolayers [\[55,56](#page-9-0)[,62,63\]](#page-10-0). For example, scanning tunneling microscopy studies [\[62\]](#page-10-0) revealed charge puddles in TMD monolayers on $SiO₂$, wherein the energies of the conduction band minima and valence band maxima varied by hundreds of meV over lateral length scales of order 10 nm. In comparison, pristine hBN provides a largely defect- and inhomogeneity-free platform for both graphene and TMD monolayers [\[54,55,](#page-9-0)[61\]](#page-10-0). As we discuss in more detail below, our time-resolved measurements of carrier valley depolarization in monolayer $WSe₂$ are consistent with a larger degree of inhomogeneity in the $SiO₂$ -supported sample B, and the formation of localized in-gap states arising from this environmental disorder, which in turn can play a role in depolarizing spins and mediating valley relaxation.

Before turning to the role of substrate-induced disorder, we discuss the spectral dependence of the measured Kerr rotation signals. As noted above, all the TRKR measurements were performed using above-gap pump pulses with fixed wavelength (645 nm, or 1.922 eV), while the probe pulses were tuned in wavelength near the peak of the induced Kerr-rotation response, which occurs in the spectral vicinity of the *X* [−] and $X⁺$ charged exciton resonances. For completeness, the full spectral dependence of the induced Kerr response from sample A is shown in Fig. [3,](#page-5-0) at different representative electron and hole densities. Here, the experiment is essentially the same as for TRKR [see Fig. $2(a)$], except that the pump diode laser and the tunable probe laser are now operated in continuous-wave (cw) mode. Thus, the measured θ_K is the induced Kerr rotation in response to a small *steady-state* (but still nonequilibrium) valley polarization of the resident carriers comprising the Fermi sea.

In our experience, a comprehensive understanding of the absorption spectrum and the optically induced Kerr spectrum is essential in studies of this type. This is because, as can

FIG. 3. Spectra showing the optically induced Kerr rotation θ_K versus probe laser energy, at selected electron and hole densities in sample A. Here, both the pump and probe lasers are operated in continuous wave (cw, not pulsed) mode. The circularly polarized cw pump laser (1.922 eV) generates a small steady-state nonequilibrium spin-valley polarization of the resident carriers. The influence of this carrier polarization is detected as a function of photon energy by the wavelength-tunable narrow-band cw probe laser. The dispersive line shapes of the θ_K resonances are centered around 1.71 eV, which corresponds to the charged exciton resonances [see Fig. $1(c)$]. The additional resonance appearing at lower energy (∼1.675 eV) in the heavily electron-doped regime corresponds to the X^{-1} feature. We emphasize that Kerr rotation derives from differences between rightand left-circularly polarized optical absorption and reflection, and as such is a direct probe of changes in real oscillator strength.

be seen from Fig. 3, relatively small variations of probe laser's photon energy with respect to the system's underlying absorption resonances can result in Kerr signals having significantly different magnitude and even opposite sign (although measured timescales are typically not affected, provided the signals derive from the same absorption resonance). Changes in signal magnitude and sign may arise trivially, due for example to exciton resonances that shift in energy (with respect to a fixed probe laser) as a function of temperature or carrier density or strain. The spectra in Fig. 3 show that the optically induced Kerr response exhibits a clear dispersive antisymmetric resonance centered near ∼1.71 eV, which coincides with the spectral position of the X^- and X^+ charged exciton resonances (cf. Fig. [1\)](#page-2-0). As discussed and shown previously [\[44,51\]](#page-9-0), this behavior is in line with expectations: a nonzero valley polarization of resident carriers is anticipated to manifest most prominently in the circular polarization of the bright X^{\pm} charged exciton resonances since the very existence of charged excitons depends explicitly of the presence of resident carriers in the monolayer.

Figure [4](#page-6-0) shows how the measured carrier valley relaxation changes with temperature (up to \sim 50 K), at various densities, in both samples A and B. Overall, τ_v decreases as temperature increases, and qualitatively similar temperaturedependent trends were also observed in previous studies of carrier valley relaxation [\[35,37,45,51](#page-9-0)[,64\]](#page-10-0). We note, however, that while τ_v varies significantly with temperature at very low doping (in sample A), it is relatively insensitive to temperatures ≤ 20 K at higher carrier densities [e.g., $p = 1.6 \times$ 10^{12} cm⁻², or $n = 2.4 \times 10^{12}$ cm⁻², as shown in Figs. [4\(a\)](#page-6-0) and $4(c)$]. In contrast, τ_v in sample B exhibits a marked temperature dependence over a wider range of carrier densities. In general, temperature-dependent valley relaxation of resident carriers can be expected if carrier-phonon interactions promote spin-flip intervalley scattering [\[28,](#page-8-0)[65–67\]](#page-10-0), either directly or via Elliot-Yafet and Dyakonov-Perel spin-relaxation mechanisms [\[68,69\]](#page-10-0), which have recently been reevaluated using *ab initio* methods for 2D materials lacking spatial inversion symmetry [\[70\]](#page-10-0).

Small applied magnetic fields provide important additional insight. Figure [5](#page-7-0) shows τ_v measured in both samples A and B, at low temperature (5.8 K), as a function of small applied out-of-plane magnetic field B_{\perp} up to ~50 mT. In sample A, τ _{*v*} is insensitive to field except at very small carrier densities [e.g., as shown in Fig. [5\(b\)](#page-7-0) where $p = 0.1 \times 10^{12}$ cm⁻²], where τ_v approximately doubles, but then saturates by 10 mT. For larger electron or hole doping, τ_v is insensitive to B_{\perp} [see Figs. $5(a)$ and $5(c)$]. In marked contrast, in sample B both τ_v and the overall valley decays show a considerable variation with B_{\perp} at all measured electron and hole carrier densities and, in particular, the faster component is rapidly suppressed with B_{\perp} [see Figs. [5\(e\)–5\(g\)\]](#page-7-0).

The sensitivity of τ_v to small B_{\perp} is perhaps somewhat surprising in view of the large spin-orbit splittings that exist between spin-up and spin-down conduction bands ($\Delta_c \sim$ 30 meV) and valence bands ($\Delta_v \sim 400$ meV) at the *K/K'* points in monolayer WSe₂. Δ_c and Δ_v impose huge out-ofplane effective magnetic fields in the range of 100–1000 T that are "seen" by electrons and holes residing at the *K* and K' points of the Brillouin zone. As such, the addition of small $B_{\perp} \approx 10$ mT should be insignificant in comparison. The experimental fact that small *B*[⊥] *does* strongly influence τ _{*v*} (at the lowest carrier densities in sample A, and over a wider density range in sample B) therefore suggests that some population of intermediate in-gap states likely participates in the $K \leftrightarrow K'$ valley relaxation process and, moreover, that these states are *not* subject to the huge effective spin-orbit magnetic fields in monolayer TMDs, possibly because they lack the inversion-asymmetric crystal symmetry of the host lattice [\[71,72\]](#page-10-0). Such states would have nearly degenerate spin levels. A potential valley relaxation pathway can therefore arise if a spin-polarized carrier from (say) the *K* valley scatters to an in-gap state and subsequently precesses about any residual in-plane effective magnetic field, and then scatters to the K' valley when its spin projection has reversed.

We note that a related intermediate-state mechanism was recently proposed to account for the circular polarization of PL from low-energy defect states in monolayer $WSe₂$ [\[73\]](#page-10-0), which was found to be similarly sensitive to small *B*⊥. As also noted in [\[73\]](#page-10-0), the sensitivity to small applied B_{\perp} is reminiscent of early optical orientation studies of spin-polarized resident electrons in *n*-type GaAs [\[10](#page-8-0)[,74\]](#page-10-0), when small *in-plane* effective magnetic fields were present due to Rashba or strain-related spin-orbit coupling. While such in-plane effective fields can depolarize out-of-plane oriented spins by inducing spin precession, their influence is readily suppressed by application of *B*⊥, which stabilizes out-of-plane spin orientation.

FIG. 4. (a)–(c) Measured valley relaxation (normalized) in sample A, at different temperatures and at three different carrier densities (i.e., in the hole-doped, approximately charge-neutral, and electron-doped regime). Points show data; lines show exponential fits. (d) τ*^v* versus temperature in sample A, for different carrier densities. (e)–(h) Same, but for sample B.

III. DISCUSSION

Taken together, the measured dependence of τ_v on carrier density, encapsulation, temperature, and B_{\perp} are consistent with a picture of electron and hole valley relaxation shown in the diagrams in Fig. [2.](#page-3-0) Once a valley polarization of the resident carriers is established by the pump pulse (following rapid exciton scattering and recombination on short timescales), the resident carrier polarization can relax either via intrinsic pathways related to density- and temperature-dependent carrier-phonon coupling, and associated Dyakonov-Perel and Elliott-Yafet mechanisms (solid lines) [\[66–70\]](#page-10-0), or it can also relax via extrinsic pathways (dotted lines) mediated by a population of in-gap states that exist due to localized defects [\[71,72\]](#page-10-0) or to the disorder potential arising from an imperfect underlying substrate. If, as the dependence on *B*[⊥] suggests, these in-gap states are not subject to the huge perpendicular effective magnetic fields from $\Delta_{c,v}$ [\[71,72\]](#page-10-0), then spin degrees of freedom at these localized sites are nearly degenerate and spins can depolarize due to precession about any residual effective fields, thereby mediating alternative relaxation pathways between the spin-valley locked carriers at *K* and *K* , in a two-step process depicted by the dotted lines. Note that in early studies of unpassivated CVD-grown TMD monolayers having significant disorder, evidence for a localized subpopulation of carriers exhibiting free spin precession at a frequency proportional only to an applied transverse field (i.e., no evidence of any large effective spin-orbit field) was reported in [\[75\]](#page-10-0) and [\[38,52\]](#page-9-0) by TRKR methods.

We argue that in lower-quality TMD monolayers such as sample B (which is in direct contact with $SiO₂$), in-gap states are likely more numerous and are more broadly distributed in energy, and therefore play a more prominent role, as compared with fully encapsulated high-quality monolayers such as sample A. Furthermore, an ensemble of in-gap states can be expected to play a more dominant role at low carrier densities when their distribution is only partially occupied, and a less important role at high carrier densities when they are full. This is consistent with the data shown in Fig. [2,](#page-3-0) where the multiexponential decays observed in sample B are most clearly evident at low electron and hole densities, but at higher carrier densities when in-gap states fill, the decays become more closely monoexponential (and also faster, as density-dependent intrinsic mechanisms begin to dominate). In comparison, the fully encapsulated sample A exhibits monoexponential decays at all carrier densities, suggesting mostly intrinsic mechanisms at play.

FIG. 5. (a)–(c) Measured valley relaxation (normalized) in sample A, at different applied out-of-plane magnetic fields *B*⊥, at three different carrier densities (in the hole-doped, approximately charge-neutral, and electron-doped regimes). All data were taken at low temperature (5.8 K). Points show data; lines show exponential fits. (d) τ_{*v*} versus *B*_⊥ in sample A, for different carrier densities. (e)–(h) Same, but for sample B, where B_{\perp} has a more marked influence on τ_v at all carrier densities.

IV. SUMMARY AND OUTLOOK

Consequently, and in summary, the data therefore suggest that the marked carrier density dependence of τ_v in sample A, which drops by over two orders of magnitude from \sim 10 μ s at low density to ~100 ns when *n*, $p \gtrsim 2 \times 10^{12}$ cm⁻² [see Fig. [2\(c\)\]](#page-3-0) is likely an intrinsic effect, due to a Fermi energy- (and momentum-) dependent valley relaxation in monolayer TMDs. It is interesting that both electron and hole doping have such similar effects on τ_v ; however, at the carrier densities and low temperatures (5.8 K) at which this study was performed, both the Fermi energy $(\leq 15 \text{ meV})$ and the thermal energy ($k_B T \approx 0.5$ meV) are always less than the spin-orbit splitting of the conduction bands in WSe₂ ($\Delta_c \approx$ 30 meV). The surprising dependence of τ_v on small outof-plane magnetic fields *B*[⊥] provides additional key insight, both by revealing the likely presence of intermediate in-gap states having negligible (or small in-plane) spin-orbit effective fields that can mix spins via precession and thereby mediate $K \leftrightarrow K'$ intervalley relaxation, and also by providing a simple means to suppress their influence so that intrinsic mechanisms can be more clearly revealed, as demonstrated in Fig. 5. Finally, the important role of substrate (dielectric) disorder on the optical properties and the valley relaxation of resident carriers is more clearly revealed by a direct side-by-side comparison of fully and partially encapsulated monolayers.

Looking forward, the steady improvement of TMD monolayer material quality and passivation methods can be expected to result in correspondingly enhanced valley lifetimes for resident carriers. The nearly monoexponential decays observed in sample A, along with the relatively small influence of out-of-plane applied magnetic fields, suggests that intrinsically limited valley lifetimes are already being approached in fully hBN encapsulated monolayers. An improved theoretical understanding of intrinsic valley relaxation mechanisms, and (especially) the strong temperature dependence and marked dependence on carrier density, will be extremely helpful in this regard. Systematic experimental studies of carrier valley lifetimes in other members of the TMD monolayer family are also warranted, particularly in Mo-based monolayers where the spin-orbit splitting of the conduction band can be much smaller than in their W-based counterparts, such that even low-electron-density Fermi seas can occupy both spin bands in each valley. Tunable manipulation of valley degrees of freedom for resident electrons and holes remains a significant challenge, but these results suggest a potential route based on intermediate states having different symmetry, at which spin degrees of freedom can in principle be more readily controlled.

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